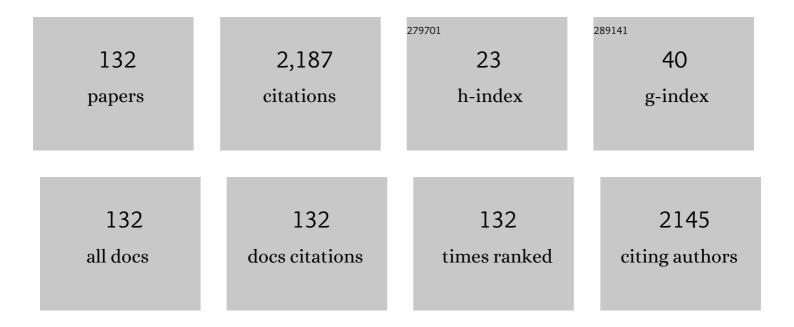
Antonio R Zanatta

List of Publications by Year in descending order

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ΑΝΤΟΝΙΟ Ρ.ΖΑΝΑΤΤΑ

#	Article	IF	CITATIONS
1	Gradual and selective achievement of Rutile-TiO2 by thermal annealing amorphous TixOyNz films. Journal of Non-Crystalline Solids, 2022, 579, 121375.	1.5	1
2	The optical bandgap of lithium niobate (LiNbO3) and its dependence with temperature. Results in Physics, 2022, 39, 105736.	2.0	11
3	Assessing the amount of the anatase and rutile phases of TiO2 by optical reflectance measurements. Results in Physics, 2021, 22, 103864.	2.0	5
4	Reducible oxide and allotropic transition induced by hydrogen annealing: synthesis routes of TiO2 thin films to tailor optical response. Journal of Materials Research and Technology, 2021, 12, 1623-1637.	2.6	12
5	On the relationship between the Raman scattering features and the Ti-related chemical states of TixOyNz films. Journal of Materials Research and Technology, 2021, 14, 864-870.	2.6	6
6	A sensitive temperature probe based on Er3+-doped GeOx films. Results in Physics, 2020, 16, 102871.	2.0	2
7	Role of Rare Earth Elements and Entropy on the Anatase-To-Rutile Phase Transformation of TiO ₂ Thin Films Deposited by Ion Beam Sputtering. ACS Omega, 2020, 5, 28027-28036.	1.6	12
8	Temperature-dependent Raman scattering of the Ge + GeOx system and its potential as an optical thermometer. Results in Physics, 2020, 19, 103500.	2.0	12
9	Revisiting the optical bandgap of semiconductors and the proposal of a unified methodology to its determination. Scientific Reports, 2019, 9, 11225.	1.6	215
10	Influence of the Anatase and Rutile phases on the luminescent properties of rare-earth-doped TiO2 films. Journal of Alloys and Compounds, 2019, 780, 491-497.	2.8	13
11	Self-organized nickel nanoparticles on nanostructured silicon substrate intermediated by a titanium oxynitride (TiNxOy) interface. AIP Advances, 2018, 8, 015025.	0.6	8
12	Whitish light-emitting ZnO micro-flakes: their production and optical properties. Optical Materials Express, 2018, 8, 270.	1.6	2
13	A suitable (wide-range + linear) temperature sensor based on Tm3+ ions. Scientific Reports, 2017, 7, 14113.	1.6	15
14	A fast-reliable methodology to estimate the concentration of rutile or anatase phases of TiO2. AIP Advances, 2017, 7, .	0.6	44
15	Coexistence of Sm^3+ and Sm^2+ ions in amorphous SiO_x: origin, main light emission lines and excitation-recombination mechanisms. Optical Materials Express, 2016, 6, 2108.	1.6	12
16	An alternative experimental approach to produce rare-earth-doped SiOx films. Journal of Applied Physics, 2016, 119, .	1.1	9
17	Temperature dependence of photoluminescence from Γ–Γ and Γ– <i>X</i> minibands in lattice matched InGaAs/InP superlattices. Journal Physics D: Applied Physics, 2015, 48, 465101.	1.3	2
18	Single-Walled Carbon Nanotubes Functionalized with Carboxylic Acid for Fabricating Polymeric Composite Microstructures. Journal of Nanoscience and Nanotechnology, 2015, 15, 9797-9801.	0.9	6

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19	Photoluminescence and compositional-structural properties of ion-beam sputter deposited Er-doped TiO2â^'xNx films: Their potential as a temperature sensor. Journal of Applied Physics, 2015, 117, .	1.1	16
20	On the structural-optical properties of Al-containing amorphous Si thin films and the metal-induced crystallization phenomenon. Journal of Applied Physics, 2014, 116, 073511.	1.1	7
21	Influence of Ni concentration on the crystallization of amorphous Si films and on the development of different Ni-silicide phases. Journal of Applied Physics, 2014, 116, 123508.	1.1	3
22	Concentration quenching of the green photoluminescence from terbium ions embedded in AlN and SiC matrices. Journal of Luminescence, 2013, 137, 73-76.	1.5	16
23	Concentration quenching and thermal activation of the luminescence from terbiumâ€doped <i>a</i> ‣iC:H and <i>c</i> â€AlN thin films. Physica Status Solidi C: Current Topics in Solid State Physics, 2013, 10, 68-71.	0.8	8
24	The Thermo Optic Coefficient of Amorphous SiN Films in the Near-Infrared and Visible Regions and Its Experimental Determination. Applied Physics Express, 2013, 6, 042402.	1.1	18
25	Efficient 1535 nm light emission from an all-Si-based optical micro-cavity containing Er^3+ and Yb^3+ ions. Optics Express, 2013, 21, 28394.	1.7	3
26	A simple-versatile approach to achieve all-Si-based optical micro-cavities. Journal of Applied Physics, 2013, 113, .	1.1	4
27	RAMAN SPECTROSCOPY OF TEMPERATURE INDUCED EFFECTS IN FOUR CARBON ALLOTROPES. Modern Physics Letters B, 2013, 27, 1350203.	1.0	2
28	Quantum-plasmonic interaction: emission enhancement of Er3+- Tm3+co-doped tellurite glass via tuning nanobowtie. , 2013, , .		3
29	Visible light emission and energy transfer processes in Sm-doped nitride films. Journal of Applied Physics, 2012, 111, .	1.1	8
30	Enhancement of optical absorption by modulation of the oxygen flow of TiO2 films deposited by reactive sputtering. Journal of Applied Physics, 2012, 111, .	1.1	28
31	Surface plasmon propagation in novel multilayered metallic thin films. , 2012, , .		2
32	Integrated hybrid plasmonic cavity with in-plane photon-plasmon coupling for luminescence enhancement. , 2012, , .		0
33	Luminescence enhancement of Er3+ions from electric multipole nanostructure arrays. , 2012, , .		4
34	Focusing surface plasmons on Er3+ ions through gold planar plasmonic lenses. Applied Physics A: Materials Science and Processing, 2012, 109, 1037-1041.	1.1	11
35	Tailored SERS substrates obtained with cathodic arc plasma ion implantation of gold nanoparticles into a polymer matrix. Physical Chemistry Chemical Physics, 2012, 14, 2050.	1.3	21
36	Exponential depletion of neutral dangling bonds density (D0) by rare-earth doping in amorphous Si films. Physica B: Condensed Matter, 2012, 407, 3222-3224.	1.3	1

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37	Integrated plasmonic Moir $ ilde{A}$ © cavity in photonic crystal cavity for luminescence enhancement. , 2012, , .		1
38	Focusing surface plasmons on Er3+ions with convex/concave plasmonic lenses. , 2012, , .		4
39	Effect of O2+, H2++ O2+, and N2++ O2+ ion-beam irradiation on the field emission properties of carbon nanotubes. Journal of Applied Physics, 2011, 109, 114317.	1.1	6
40	Influence of film thickness on the optical transmission through subwavelength single slits in metallic thin films. Applied Optics, 2011, 50, G11.	2.1	18
41	Development of the MnSi1.7 phase in Mn-containing Si films. Materials Chemistry and Physics, 2011, 129, 148-153.	2.0	12
42	Structural–electronic aspects related to the near-infrared light emission of Fe-doped silicon films. Solid State Communications, 2011, 151, 587-590.	0.9	0
43	Raman spectroscopy analysis of structural photoinduced changes in GeS2+Ga2O3 thin films. Current Applied Physics, 2010, 10, 1411-1415.	1.1	5
44	Effect of Mn concentration and atomic structure on the magnetic properties of Ge thin films. Journal of Applied Physics, 2010, 108, 113922.	1.1	7
45	Influence of chromium concentration on the optical–electronic properties of ruby microstructures. Journal Physics D: Applied Physics, 2010, 43, 015302.	1.3	7
46	Structural, optical and morphological characterization of amorphous Ge _{100â^'<i>x</i>} Mn _{<i>x</i>} films deposited by sputtering. Journal Physics D: Applied Physics, 2009, 42, 035005.	1.3	10
47	Evidence of magnetic vortices formation in Mn-based sub-micrometre structures embedded in Si–Mn films. Journal Physics D: Applied Physics, 2009, 42, 132002.	1.3	6
48	Effect of thermal annealing treatments on the optical properties of rare-earth-doped AlN films. Journal Physics D: Applied Physics, 2009, 42, 025109.	1.3	27
49	Electrophoretic deposition of Ba0.77Ca0.23TiO3 nanopowders. Journal of Materials Processing Technology, 2008, 203, 526-531.	3.1	8
50	Resonant excitation of Mn local vibrational modes in the higher order Raman spectra of nanocrystalline Ga1â ^{~2} xMnxN films. Journal of Physics Condensed Matter, 2008, 20, 252201.	0.7	5
51	Influence of film thickness on the crystallization of Ni-doped amorphous silicon samples. Journal of Applied Physics, 2008, 104, .	1.1	8
52	Aluminium-induced nanocrystalline Ge formation at low temperatures. Journal of Physics Condensed Matter, 2007, 19, 076206.	0.7	12
53	Red–green–blue light emission and energy transfer processes in amorphous SiN films doped with Sm and Tb. Journal of Physics Condensed Matter, 2007, 19, 436230.	0.7	7
54	Crystallization, stress, and stress-relieve due to nickel in amorphous silicon thin films. Journal of Applied Physics, 2007, 102, .	1.1	11

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55	Amorphous BeN as a new solid host for rare-earth-related luminescent materials. Physica Status Solidi - Rapid Research Letters, 2007, 1, 153-155.	1.2	4
56	Thermally synthesized ruby microstructures and luminescence centers. Journal of Applied Physics, 2006, 100, 113112.	1.1	5
57	Spectroscopic investigation of Nd-doped amorphous SiN films. Journal of Non-Crystalline Solids, 2006, 352, 1286-1289.	1.5	Ο
58	Metal-induced nanocrystalline structures in Ni-containing amorphous silicon thin films. Journal of Applied Physics, 2006, 100, 094311.	1.1	26
59	Thermal activation, cathodo- and photoluminescence measurements of rare earth doped (Tm,Tb,Dy,Eu,Sm,Yb) amorphous/nanocrystalline AIN thin films prepared by reactive rf-sputtering. Optical Materials, 2006, 28, 790-793.	1.7	48
60	Crystallization, texture and second-harmonic generation in TiO2–BaO–B2O3 glasses. Optical Materials, 2006, 28, 935-943.	1.7	20
61	Optical properties of Er and Er+Yb doped hydrogenated amorphous silicon films. Journal of Physics Condensed Matter, 2006, 18, 7709-7716.	0.7	5
62	Effect of the initial structure of silicon surface on the generation of multiple structural phases by cyclic microindentation. Applied Physics Letters, 2006, 89, 031917.	1.5	16
63	Annealing effects on crystallized Al-doped a-Ge:H thin films. Physica Status Solidi C: Current Topics in Solid State Physics, 2005, 2, 3750-3753.	0.8	Ο
64	Annealing crystallization of a-Ge/Al/Si and a-Ge/Si thin films. Physica Status Solidi (B): Basic Research, 2005, 242, 1906-1909.	0.7	1
65	Low-temperature Al-induced crystallization of amorphous Ge. Journal of Applied Physics, 2005, 97, 094914.	1.1	45
66	Optoelectronic and structural characteristics of Er-doped amorphous AlN films. Journal of Applied Physics, 2005, 98, 093514.	1.1	19
67	Formation of silicon nanocrystals in SiO[sub 2] by oxireduction reaction induced by impurity implantation and annealing. Journal of Vacuum Science & Technology an Official Journal of the American Vacuum Society B, Microelectronics Processing and Phenomena, 2004, 22, 1669.	1.6	4
68	Spectroscopic study of Nd-doped amorphous SiN films. Journal of Applied Physics, 2004, 96, 1068-1073.	1.1	16
69	Synthesis and Characterization of the Â-BaB2O4Phase Obtained by the Polymeric Precursor Method. Journal of Sol-Gel Science and Technology, 2004, 29, 89-96.	1.1	17
70	β-BaB2O4 nanometric powder obtained from the ternary BaO–B2O3–TiO2 system using the polymeric precursor method. Materials Science and Engineering B: Solid-State Materials for Advanced Technology, 2004, 107, 33-38.	1.7	12
71	Synthesis and characterization of beta barium borate thin films obtained from the BaO–B2O3–TiO2 ternary system. Thin Solid Films, 2004, 457, 246-252.	0.8	7
72	Laser-induced generation of micrometer-sized luminescent patterns on rare-earth-doped amorphous films. Journal of Applied Physics, 2004, 96, 5977-5981.	1.1	17

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73	Comprehensive spectroscopic study of nitrogenated carbon nanotubes. Physical Review B, 2004, 69, .	1.1	65
74	Photoluminescence of a-GeN alloys doped with different rare-earth ions. Journal of Non-Crystalline Solids, 2004, 338-340, 469-472.	1.5	5
75	Photon and electron excitation of rare-earth-doped amorphous SiN films. Journal of Non-Crystalline Solids, 2004, 338-340, 473-476.	1.5	10
76	Amorphous hydrogenated carbon films deposited by PECVD: influence of the substrate temperature on film growth and microstructure. Journal of Non-Crystalline Solids, 2004, 338-340, 503-508.	1.5	14
77	Thermal lens and non-linear optical absorption study of a-SiH films. Journal of Non-Crystalline Solids, 2004, 348, 230-234.	1.5	5
78	Neutral dangling bond depletion in amorphous SiN films induced by magnetic rare-earth elements. Solid State Communications, 2003, 128, 47-50.	0.9	1
79	Unusual Interactions Binding Iron Tetrasulfonated Phthalocyanine and Poly(allylamine) Tj ETQq1 1 0.784314 rgBT	/Overlock 1.2	10 Tf 50 50
80	X-ray photoelectron spectroscopic study of rare-earth-doped amorphous silicon–nitrogen films. Journal of Applied Physics, 2003, 93, 1948-1953.	1.1	9
81	Photoluminescence quenching in Er-doped compounds. Applied Physics Letters, 2003, 82, 1395-1397.	1.5	50
82	Magnetic properties of amorphous Si films doped with rare-earth elements. Physical Review B, 2003, 68,	1.1	8
83	Synthesis and spectroscopic investigation of ruby microstructures. Applied Physics Letters, 2003, 83, 2336-2338.	1.5	4
84	Laser Interference Structuring of a-GeN for the Production of Optical Diffraction Gratings. Materials Research Society Symposia Proceedings, 2003, 762, 1741.	0.1	0
85	Laser interference structuring of a-Ge films on GaAs. Journal of Applied Physics, 2002, 91, 2916-2920.	1.1	4
86	Optical diffraction gratings produced by laser interference structuring of amorphous germanium–nitrogen alloys. Applied Physics Letters, 2002, 81, 2731-2733.	1.5	5
87	Structural properties of aluminum–nitrogen films prepared at low temperature. Applied Physics Letters, 2002, 81, 1005-1007.	1.5	24
88	Comment on "lon-assisted pulsed laser deposition of aluminum nitride thin films―[J. Appl. Phys.87, 1540 (2000)]. Journal of Applied Physics, 2002, 92, 6349-6350.	1.1	1
89	Pulsed laser crystallization and structuring of a-Ge on GaAs. Journal of Non-Crystalline Solids, 2002, 299-302, 137-142.	1.5	2
90	Microscopic mechanisms behind the Al-induced crystallization of a-Ge:H films. Journal of Non-Crystalline Solids, 2002, 299-302, 143-147.	1.5	8

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91	X-ray photoelectron spectroscopy of amorphous AlN alloys prepared by reactive rf sputtering. Journal of Non-Crystalline Solids, 2002, 299-302, 323-327.	1.5	4
92	Red and Green Light Emission From Samarium-Doped Amorphous Aluminum Nitride Films. Advanced Materials, 2002, 14, 1154.	11.1	15
93	Plasma deposition of amorphous carbon films from CH4 atmospheres highly diluted in Ar. Thin Solid Films, 2002, 419, 46-53.	0.8	24
94	Magnetic properties of gadolinium-doped amorphous silicon films. Brazilian Journal of Physics, 2002, 32, 409-411.	0.7	4
95	Structural properties of hydrogenated carbon-nitride films produced by ion-beam-assisted evaporation of the molecular precursor C4N6H4. Journal of Applied Physics, 2001, 89, 7852-7859.	1.1	2
96	Visible luminescence from a-SiN films doped with Er and Sm. Applied Physics Letters, 2001, 79, 488-490.	1.5	33
97	Epitaxial pulsed laser crystallization of amorphous germanium on GaAs. Journal of Applied Physics, 2001, 90, 2575-2581.	1.1	9
98	Aluminum-induced crystallization of hydrogenated amorphous germanium thin films. Applied Physics Letters, 2001, 79, 3233-3235.	1.5	39
99	Optoelectronic and structural properties of Er-doped sputter-deposited gallium–arsenic–nitrogen films. Journal of Applied Physics, 2001, 90, 2321-2328.	1.1	3
100	Effects of SiH[sub 2]Cl[sub 2] on the Deposition and Properties of Amorphous and Microcrystalline Silicon Fabricated from Very High Frequency Glow Discharges. Journal of the Electrochemical Society, 2000, 147, 1829.	1.3	6
101	Optical study of thermally annealed Er-doped hydrogenatedaâ^'Sifilms. Physical Review B, 2000, 62, 2016-2020.	1.1	16
102	Infrared photoluminescence from Er-doped a-GaAsN alloys. Journal of Non-Crystalline Solids, 2000, 266-269, 854-858.	1.5	1
103	Microcrystalline silicon with high electron field-effect mobility deposited at 230°C. Journal of Non-Crystalline Solids, 2000, 266-269, 1260-1264.	1.5	31
104	Photoelectron spectroscopic study of amorphous GaAsN films. Applied Physics Letters, 2000, 76, 2211-2213.	1.5	10
105	Visible photoluminescence fromEr3+ions inaâ^'SiNalloys. Physical Review B, 1999, 59, 10091-10098.	1.1	20
106	1540 nm light emission from Er-doped amorphous GaAsN films. Applied Physics Letters, 1999, 75, 3279-3281.	1.5	13
107	Optical and structural properties of laser annealed Er-doped amorphous silicon thin films. Journal of Applied Physics, 1999, 86, 701-703.	1.1	15
108	Optical excitation of Er3+ ions in a-SiN alloys. Journal of Applied Physics, 1999, 86, 338-341.	1.1	13

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109	1.54 μm photoluminescence of Er-containing N-doped a-Si:H. Journal of Non-Crystalline Solids, 1998, 227-230, 389-393.	1.5	3
110	Erbium luminescence in a-Si:H. Journal of Non-Crystalline Solids, 1998, 227-230, 399-402.	1.5	7
111	Green photoluminescence from Er-containing amorphous SiN thin films. Applied Physics Letters, 1998, 72, 3127-3129.	1.5	70
112	Optical spectroscopy of Er3+ and Yb3+ co-doped fluoroindate glasses. Journal of Applied Physics, 1998, 83, 2256-2260.	1.1	49
113	Nitrogen in germanium. Journal of Applied Physics, 1998, 84, 1-30.	1.1	102
114	Exponential absorption edge and disorder in Column IV amorphous semiconductors. Journal of Applied Physics, 1998, 84, 5184-5190.	1.1	31
115	Infrared spectroscopy of Er-containing amorphous silicon thin films. Applied Physics Letters, 1997, 71, 3679-3681.	1.5	16
116	Erbium luminescence from hydrogenated amorphous silicon-erbium prepared by cosputtering. Applied Physics Letters, 1997, 70, 511-513.	1.5	59
117	Electronic structure of amorphous germanium-nitrogen alloys: a UV photoelectron spectroscopy study. Journal of Non-Crystalline Solids, 1996, 198-200, 136-139.	1.5	2
118	Absorption edge, band tails, and disorder of amorphous semiconductors. Physical Review B, 1996, 53, 3833-3836.	1.1	156
119	XPS study of non-stoichiometric amorphous GeN alloys (a-GeNx, 0≤â‰ੳ.3). AIP Conference Proceedings, 1996, , .	0.3	3
120	Valence band structure of amorphous germanium-nitrogen alloys. AIP Conference Proceedings, 1996, ,	0.3	2
121	Bond distribution and structure of amorphous germaniumâ€nitrogen alloys. Physica Status Solidi (B): Basic Research, 1996, 193, 399-410.	0.7	6
122	Study of structural changes in amorphous germanium–nitrogen alloys by optical techniques. Journal of Applied Physics, 1996, 79, 433-438.	1.1	10
123	The Perspectives of Hydrogenated Amorphous Germanium as an Electronic Material. Physica Status Solidi (B): Basic Research, 1995, 192, 241-251.	0.7	5
124	Local electronegativity and chemical shift in Si and Ge based molecules and alloys. Solid State Communications, 1995, 95, 207-210.	0.9	12
125	Study of amorphous germaniumâ€nitrogen alloys through xâ€ray photoelectron and Auger electron spectroscopies. Applied Physics Letters, 1995, 66, 1258-1260.	1.5	10
126	Photoelectron spectroscopy of shallow core levels using He II(40.8 eV) excitation. Journal of Vacuum Science and Technology A: Vacuum, Surfaces and Films, 1995, 13, 2278-2280.	0.9	2

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127	Photoconductivity of intrinsic and nitrogenâ€doped hydrogenated amorphous germanium thin films. Journal of Applied Physics, 1994, 75, 4662-4667.	1.1	12
128	Infrared absorption and composition of amorphous germanium-nitrogen alloys. Journal of Physics Condensed Matter, 1993, 5, A313-A314.	0.7	1
129	On the doping efficiency of nitrogen in hydrogenated amorphous germanium. Applied Physics Letters, 1993, 62, 58-60.	1.5	19
130	Nitrogen in the amorphous-germanium network: From high dilution to the alloy phase. Physical Review B, 1993, 48, 4560-4570.	1.1	34
131	Transport properties of nitrogen-doped hydrogenated amorphous germanium films. Physical Review B, 1992, 46, 2119-2125.	1.1	30
132	Extended x-ray-absorption fine-structure investigation of short-range order ina-Ge1â^'xSnxalloys. Physical Review B, 1992, 46, 6718-6723.	1.1	15